## Kinetic mechanisms in CO<sub>2</sub>-N<sub>2</sub> plasmas

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**Abstract** (about 150 words with free format)

This contribution reports the comparison of simulation results from a 0D self-consistent kinetic model with recent experimental data obtained in low-pressure DC discharges in  $CO_2$ - $N_2$ . This work will thus contribute to further develop the existing models [1-3] and will allow us to investigate the impact of  $N_2$  on the plasma kinetics, relevant, since the admixture of  $N_2$  is beneficial for  $CO_2$  decomposition [1,4].

The system of election is a DC glow discharge, operating at a few Torrs and tens of mA in a Pyrex tube of radius 1 cm. The set of measurements provides the gas temperature, vibrational temperatures of CO and the various modes of CO<sub>2</sub>, reduced field E/N, and densities of O( $^3$ P), CO( $X^1\Sigma^+$ ) and CO<sub>2</sub>( $X^1\Sigma^+$ g). The simulations are carried out with the LoKI simulation tool [5]. The reasons underlaying the positive effect of N<sub>2</sub> in CO<sub>2</sub> dissociation will be discussed at the conference.

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